

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: ISHIHARA et al

Application No.: Continuation of U.S. Patent Application
Serial No. 09/949,091, filed September 10, 2001

Filed: July 1, 2003

For: IC CARD APPARATUS HAVING PATTERNED INSULATING
LAYER FORMED BETWEEN GATE INSULATING FILM AND
SEMICONDUCTOR LAYER EXCEPT FOR CHANNEL REGION
AND METHOD OF MANUFACTURE (AS AMENDED)

Prior Art Unit: 2871

Prior Examiner: Tarifur Rashid CHOWDHURY

PRELIMINARY AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

July 1, 2003

Sir:

Please amend the above-identified application, prior to examination thereof, as follows:

IN THE SPECIFICATION:

Page 1, between the title and the heading "BACKGROUND OF THE INVENTION", please add the following new paragraph:

--This application is a Continuation application of Application No. 09/949,091, filed September 10, 2001, which is a Continuation application of Application No. 09/526,557, filed March 16, 2000, the contents of which are incorporated herein by reference in their entirety.--